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PATENT NUMBER and
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM 10073415	FILING DATE 02/13/2002	CLASS 430	SUBCLASS S	GAU 1756	EXAMINER Rosasco
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****CONTINUING DATA VERIFIED:**

SLW

**** FOREIGN APPLICATIONS VERIFIED:**

JAPAN 2001-035783 02/13/2001

AR

PG-PUB	DO NOT PUBLISH <input type="checkbox"/>	RESCIND <input type="checkbox"/>	
Foreign priority claimed <input checked="" type="checkbox"/> yes <input type="checkbox"/> no		ATTORNEY DOCKET NO	
35 USC 119 conditions met <input checked="" type="checkbox"/> yes <input type="checkbox"/> no		0171-0819P	
Verified and Acknowledged Examiners's initials <i>AR</i>			
TITLE : Photomask blank, photomask and method of manufacture			

U.S. DEPT. OF COMM./PAT. & TM.-PTO-436L (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	Print Claim for O.G.
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Shoots Drwg.	Figs.Drwg. Print Fig.
<input type="checkbox"/> TERMINAL DISCLAIMER		Application Examiner	
		PREPARED FOR ISSUE	
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